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# Embedding of Active Components in LCP for Implantable Medical Devices

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#### **BACKGROUND AND GOALS**

**Liquid crystal polymer (LCP) dielectric** has been demonstrated as feasible for producing directly implantable, biocompatible structures without the need for hermetic coatings or housings [1,2].

- Neural interfaces and electrodes can be fabricated based on flex circuit manufacturing techniques using biocompatible material sets
- Achieve significantly smaller form factors
- Incorporate complex features, channels and routings through the use of photolithography and laser drilling
- Enhancing functionality by embedding active and passive components within the implantable structures thanks to the very low moisture uptake of LCP

References:

[1] J. Jeung, et al., "A novel multilayered planar coil based on biocompatible liquid crystal polymer for chronic pain implantation," *Sensors and Actuators A: Physical*, Volume 197, 1 August 2013, pp. 38-46.

[2] S.W. Lee, et al., "Development of Microelectrode Arrays for Artificial Retinal Implants Using Liquid Crystal Polymers," *IOVS*, December 2009, Vol. 50, No. 12, pp. 5859-5866.





## LIQUID CRYSTAL POLYMER (LCP) PROPERTIES

- LCP is a thermoplastic material
- Operating temperature up to 190° C
- Melting point at 280°C
- Can be transfer molded to any shape
- Density 1.4 g/cm3
- Low water absorption < 0.04%
- Fully biocompatible according to ISO 10993-5 (in vitro cytotoxicity)







## **EXAMPLES OF BIOCOMPATIBLE LCP STRUCTURES**

Electrodes and neural interface structures fabricated on conventional flex circuit manufacturing equipment combined with thin film technology



![](_page_4_Picture_0.jpeg)

![](_page_4_Picture_1.jpeg)

## **BIOCOMPATIBLE CONDUCTOR TECHNOLOGY**

- Conductor material pure gold
- Minimum line width 30 μm
- Minimum spacing between traces 20 µm
- Conductor thickness between 2...15 µm
- Line resistance between 0.1...1  $\Omega$ /cm
- Resistance has a linear temperature coefficient and can be used to measure temperature

![](_page_4_Figure_9.jpeg)

#### **Completely Biocompatible Structure**

![](_page_4_Picture_11.jpeg)

LCP lead structure with electrodes on the surface and embedded metal traces from pure gold

![](_page_5_Picture_0.jpeg)

![](_page_5_Picture_1.jpeg)

#### **NOBLE METAL TRACES AND VIAS**

![](_page_5_Figure_3.jpeg)

![](_page_6_Picture_0.jpeg)

![](_page_6_Picture_1.jpeg)

## SEALED INTERCONNECTS BETWEEN CABLES

- New fully biocompatible interconnect technology for implanted leads
- Extension of maximum lead length
- Solderless & glueless
- Local applied heat pulse under pressure melts LCP and seals contacts
- Pull strength 20 N/mm same as lead body

![](_page_6_Picture_8.jpeg)

![](_page_7_Picture_0.jpeg)

![](_page_7_Picture_1.jpeg)

#### HIRES TIP ELECTRODE

#### High resolution with pure gold traces for biocompatible, neurostimulation electrode

![](_page_7_Figure_4.jpeg)

100 µm

![](_page_8_Picture_0.jpeg)

![](_page_8_Picture_1.jpeg)

## HIGH RESOLUTION ELECTRODE FOR BRAIN INTERFACE

Application: Implanted electrode for 4 x 64 Channel EEG for animal tests

- 16 x 16 Matrix of electrodes with 0.75 mm pitch
- Pure gold traces with 30  $\mu m$  line width/spacing
- Traces embedded in LCP
- Electrode diameter 75 µm

![](_page_8_Figure_8.jpeg)

![](_page_9_Picture_0.jpeg)

![](_page_9_Picture_1.jpeg)

#### **METHODS – RELIABILITY EVALUATION**

- LCP film used as the dielectric material with noble metal conductors such as Au, Pt and PtIr
- Appropriate cleaning processes used to ensure biocompatibility of the final structures[3]
- Mock silicon die patterned with Cu embedded within the LCP to produce test structures for hermeticity studies
- Long term biostability evaluations performed by soak tests in heated phosphate-buffered saline (PBS)
- Bend testing at a 0.5 mm radius conducted for mechanical reliability
- Cross-sectional analysis used to examine regions of failure

[3] ISO 10993-1:2009 Biological evaluation of medical devices – Part 1: Evaluation and testing with a risk management process.

![](_page_10_Picture_0.jpeg)

#### **TEST CHIP DESIGN**

#### Test chip for embedding

- Manufacturer: TLMI, Austin, Texas
- Wafer diameter: 150 mm
- Active wafer diameter: 147 mm
- Wafer thickness: 100 µm (thinned)
- Die surface: thermal oxide
- Adhesion promoter: TiW (sputtered)
- Metallization: 3 µm copper & gold flash
- Chip dimensions: 5 x 8 mm

#### Artwork on die

- Pad size: 250 x 250 µm (thinned)
- Interdigitized comb structure with 50 µm lines & spaces

![](_page_10_Picture_15.jpeg)

![](_page_10_Picture_16.jpeg)

![](_page_10_Picture_17.jpeg)

![](_page_10_Picture_18.jpeg)

![](_page_11_Picture_0.jpeg)

![](_page_11_Picture_1.jpeg)

#### **TEST CHIP EMBEDDED IN LCP**

![](_page_11_Picture_3.jpeg)

![](_page_12_Picture_0.jpeg)

![](_page_12_Picture_1.jpeg)

#### **EMBEDDED DIE TEST STRUCTURE FOR SOAK TESTS**

Contact pads on electrode layer (1)

Embedded traces on redistribution layer (2)

Embedded die with pads on layer (3)

Grid structure on backside (4)

![](_page_12_Picture_7.jpeg)

![](_page_13_Picture_0.jpeg)

![](_page_13_Picture_1.jpeg)

#### **TEST CHIP TO OUTLINE DISTANCES**

![](_page_13_Figure_3.jpeg)

Layer 2 copper / outline distance

![](_page_13_Figure_5.jpeg)

#### Layer 3 chip artwork / outline distance

![](_page_14_Picture_0.jpeg)

![](_page_14_Picture_1.jpeg)

#### **BEND TESTING APPARATUS AND METHOD**

#### FIGURE 6

![](_page_14_Figure_4.jpeg)

![](_page_15_Picture_0.jpeg)

![](_page_15_Picture_1.jpeg)

#### SOAK TESTING APPARATUS

![](_page_15_Picture_3.jpeg)

#### FIGURE 7

![](_page_16_Picture_0.jpeg)

![](_page_16_Picture_1.jpeg)

### RESULTS

- Noble metal LCP based neural interface and electrode structures successfully fabricated using conventional flex circuit and thin film processing
- Structures that undergo specialized cleaning operations pass the ISO 10993 cytotoxicity test requirements
- LCP structures with Au conductors passed PBS soak testing at 77°C for > 9 months without failure

![](_page_17_Picture_0.jpeg)

![](_page_17_Picture_1.jpeg)

#### PBS SOAK (90°C) TEST RESULTS OF EMBEDDED DIE IN LCP STRUCTURES

SAMPLE	1	2	3	4	5	6	7	8	9	10
Time to value below range limit of 10 GΩ [h]	1'536	1'104	168	840	168	600	384	936	864	336
Saturation Value	> 1GΩ	1.6 MΩ	14 MΩ	0.9 MΩ	21.5 kΩ	2 MΩ	3 kΩ	3 MΩ	5 ΜΩ	0.2 MΩ

- A resistance reduction was observed in 9 out of 10 samples, occurring between 168 and 864 hours @ 90 °C in PBS
- One sample did not show any reduction of resistance below the range limit of 10 G  $\Omega$  until 1'536 hours, when the test was terminated

![](_page_18_Picture_0.jpeg)

![](_page_18_Picture_1.jpeg)

#### SOAK TEST RESULT

![](_page_18_Figure_3.jpeg)

![](_page_19_Picture_0.jpeg)

![](_page_19_Picture_1.jpeg)

## **FAILURE ANALYSIS**

- Adhesion between laminated layers was found to be reduced significantly after the soaking test, indicating that moisture penetration is likely the reason for reduced resistance in the comb structure
- Foreign material, which is embedded between the layers, can act as defect side to enhance the moisture migration
- Further work needed to reduce moisture penetration along the interfaces

![](_page_19_Picture_6.jpeg)

Evidence of Cu Electromigration

![](_page_19_Picture_8.jpeg)

Top layer LCP peeled back on failed electrode structures

![](_page_20_Picture_0.jpeg)

![](_page_20_Picture_1.jpeg)

### **RECENT SOAK TEST RESULTS**

TEST	LCP STRUCTURE	RESULT
Soak test in PBS at 77° C	LCP with Au traces	<ul> <li>9 months continuous</li> <li>(equivalent to 15 years</li> <li>implanted in body)</li> </ul>
Soak test in PBS at 50° C	LCP with Cu traces, embedded die	Ongoing test (no measureable drop in resistance after >1800 hours)
Soak test in 40% $H_2SO_4$ at 50° C	LCP with Cu traces, embedded die	Ongoing test (no measureable drop in resistance after >1800 hours)
Soak test in 80% $H_2SO_4$ at 50° C	LCP with Cu traces, embedded die	Ongoing test (no measureable drop in resistance after >1800 hours)

![](_page_21_Picture_0.jpeg)

![](_page_21_Picture_1.jpeg)

#### CONCLUSIONS

- Biocompatible neural interfaces and electrode structures can be fabricated from LCP dielectric and noble metal conductors on conventional flex circuit and thin film manufacturing equipment.
- Passive structures have shown initial feasibility for long term biostability based on PBS soak testing.
- Structures with embedded die show initial promise for biostability, but further process optimization is needed.
- The results demonstrate that a new material set comprised of LCP with noble metals is feasible for producing complex implantable structures for neuromodulation applications.

![](_page_22_Picture_0.jpeg)

![](_page_22_Picture_1.jpeg)

#### REFERENCES

- [1] J. Jeung, et al., "A novel multilayered planar coil based on biocompatible liquid crystal polymer for chronic pain implantation," *Sensors and Actuators A: Physical*, Volume 197, 1 August 2013, pp. 38-46.
- [2] S.W. Lee, et al., "Development of Microelectrode Arrays for Artificial Retinal Implants Using Liquid Crystal Polymers," *IOVS*, December 2009, Vol. 50, No. 12, pp. 5859-5866.
- [3] ISO 10993-1:2009 Biological evaluation of medical devices Part 1: Evaluation and testing with a risk management process.

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